

ANNOTATED SHEET SHOWING CHANGES

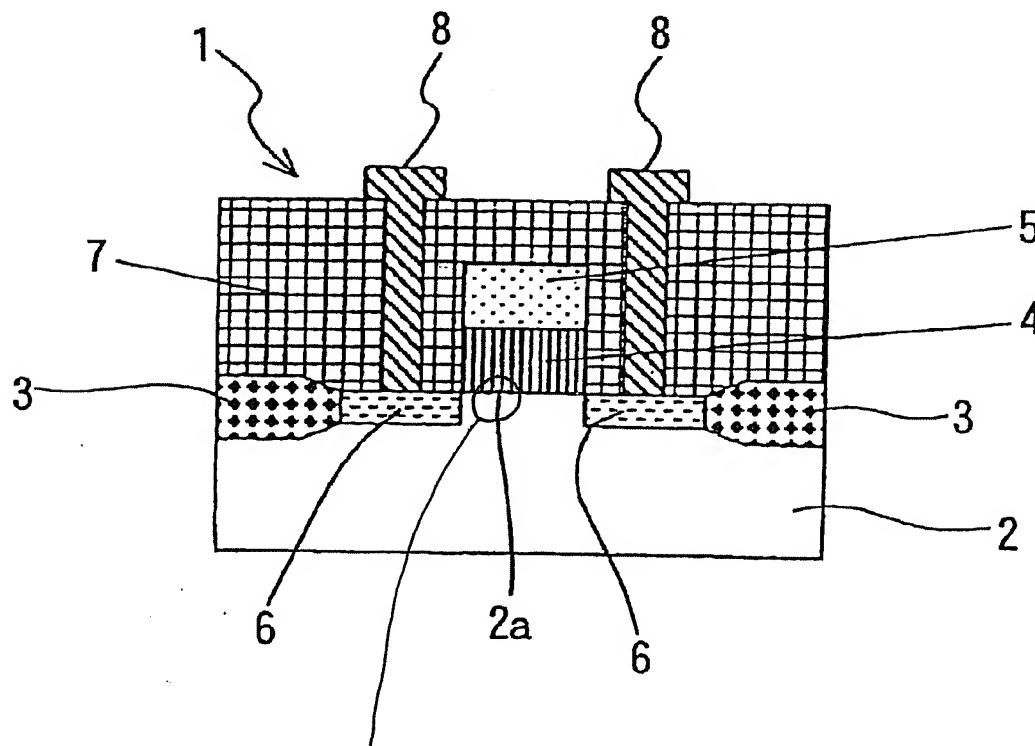
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Title: METHOD FOR FORMING AN INSULATING FILM IN A SEMICONDUCTOR DEVICE

S/N: 10/550,805

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Fig. 1



Clarified that reference 2a
indicates the surface of
substrate 2, as noted on
page 5, line 4 of the present
specification